

# Synthesis and characterization of d-UO<sub>2</sub> nanoparticles for nuclear fuel microanalysis

Presented by:

**Samuel A. Briggs**

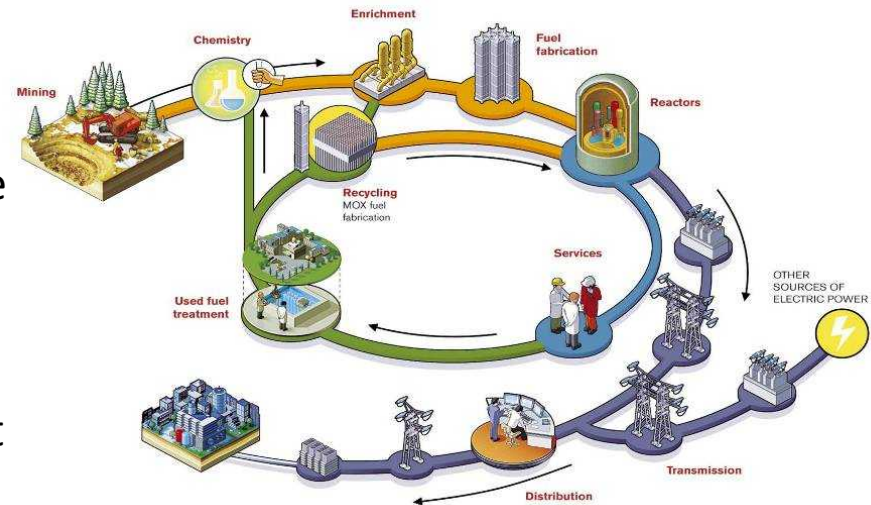
Co-authors: B.E. Klamm, R.F. Hess, K. Hattar



Sandia National Laboratories is a multimission laboratory managed and operated by National Technology and Engineering Solutions of Sandia, LLC, a wholly owned subsidiary of Honeywell International, Inc., for the U.S. Department of Energy's National Nuclear Security Administration under contract DE-NA0003525.

# Motivation

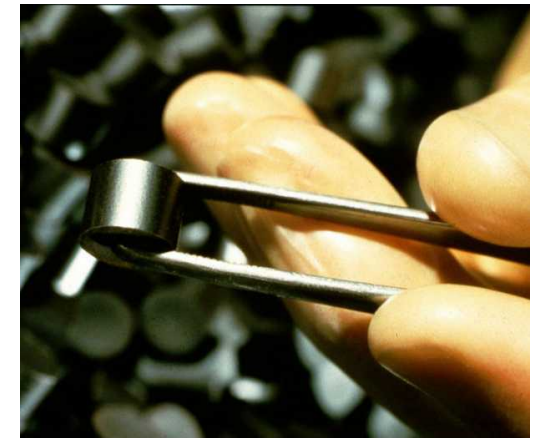
- Uranium dioxide ( $\text{UO}_2$ ) has been used as a commercial LWR fuel since the inception of nuclear power
- $\text{UO}_2$  processing route has remained the same for the past 60+ years
  - $\text{Ore} > \text{U}_3\text{O}_8 > \text{UF}_6 > \text{Enrichment} > \text{UO}_2$
- Other novel synthesis routes and potential applications of different forms of  $\text{UO}_2$  are yet to be explored
  - $\text{UO}_2$  in nanoparticle or thin film forms may have both research and industrial applications



Yellowcake Uranium ( $\text{U}_3\text{O}_8$ )  
Photo: Ivan Pierre Aguirre/Texas Tribune



Uranium Hexafluoride ( $\text{UF}_6$ )  
Photo: AREVA

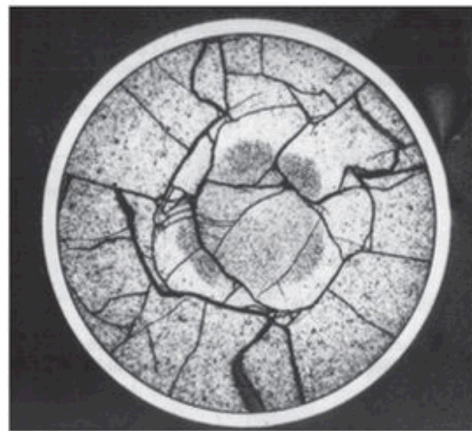


Uranium Dioxide ( $\text{UO}_2$ )  
Photo: NRC

# Why UO<sub>2</sub> Nanoparticles & Films?

- Small quantities of depleted uranium are more easily handled in lab environments
  - Allow for fundamental studies of materials properties/behavior for nuclear fuel applications
- Can deposit more easily on substrates (sputter or grow single crystals)
  - Likely necessary for semiconductor applications<sup>1</sup>
  - Also potentially useful for studies of interfaces
- Eliminates need for involved sample preparation for TEM investigation
  - Can deposit directly on lacey carbon or Si<sub>3</sub>N<sub>4</sub> grids
- Greater control over microstructure and stoichiometry via different processing routes

	UO <sub>2</sub>	GaAs	Si
Band Gap	1.30 eV	1.39 eV	1.14 eV
Dielectric constant	22	12.9	11.7
Max Temperature	2600 K	470 K	470 K

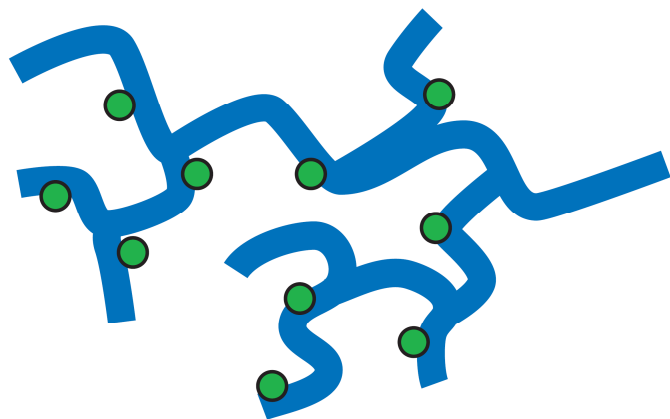


[1] T. T. Meek & B. von Roedern, *Semiconductor devices fabricated from actinide oxides*. Vacuum **83** (2008) pp. 226-228.

[2] R.C. Ewing, *Long-term storage of spent nuclear fuel*. Nature Materials **14** (2015) pp. 252-257.

## ■ Polymer assisted deposition (PAD)

- Binding to polymers homogeneously distributes metal in solution
- Air- and water-stable precursors
- Flexible application to substrate – spin, dip, spray-coat, drop-cast, etc
- Thermal decomposition of metal polymer leads to high density films and/or particles



Metals evenly  
spaced on polymer



Polyethylenimine  
(PEI)

# UO<sub>2</sub> Nanoparticle Synthesis

- Reagents, in aqueous solution with DI H<sub>2</sub>O

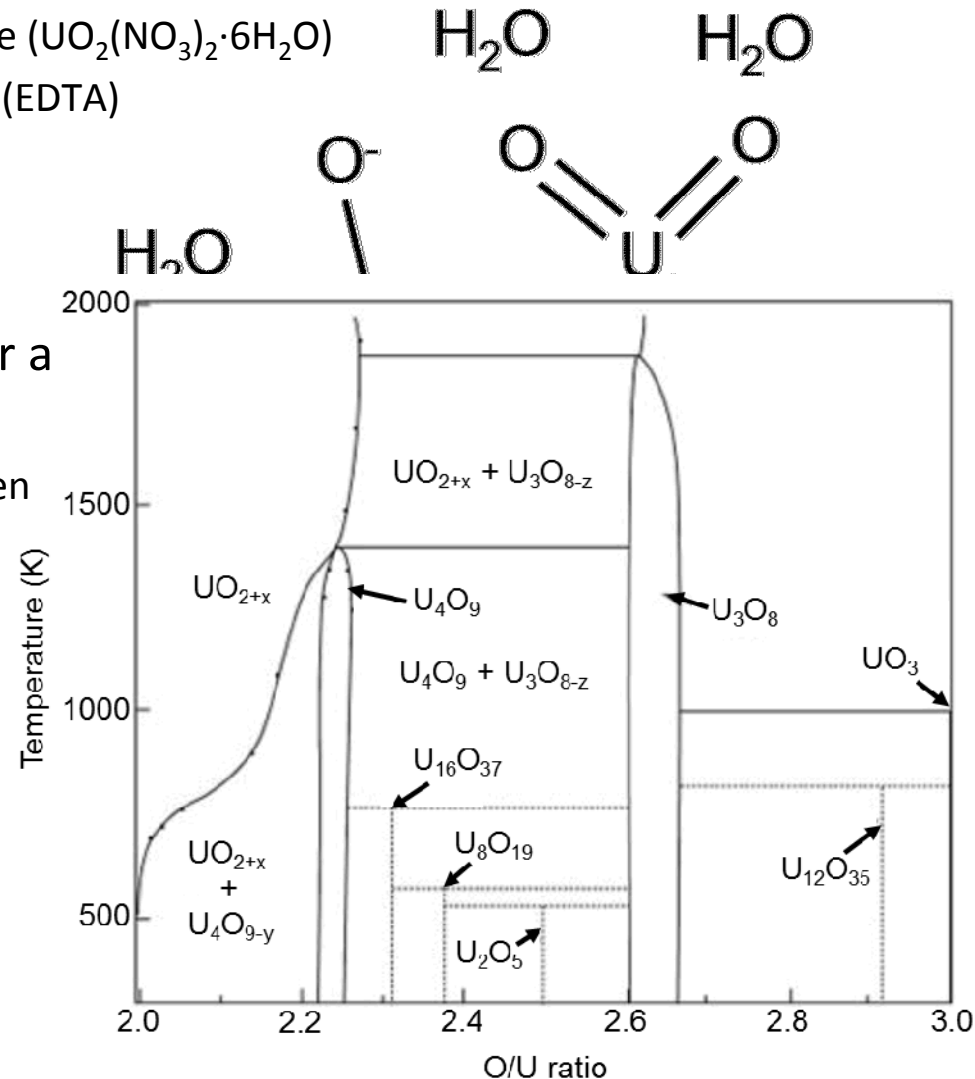
- 0.1 M depleted uranyl nitrate hexahydrate (UO<sub>2</sub>(NO<sub>3</sub>)<sub>2</sub>·6H<sub>2</sub>O)
- 0.125 M ethylenediaminetetraacetic acid (EDTA)
- 0.125 M polyethylenimine (PEI)
- Nitric acid (HNO<sub>3</sub>, to adjust pH to 7.5)

- Drop cast on either Si<sub>3</sub>N<sub>4</sub> TEM grids or a Zircaloy-4 substrate

- Zr-4 was heated to 150 °C for 30 s between additions

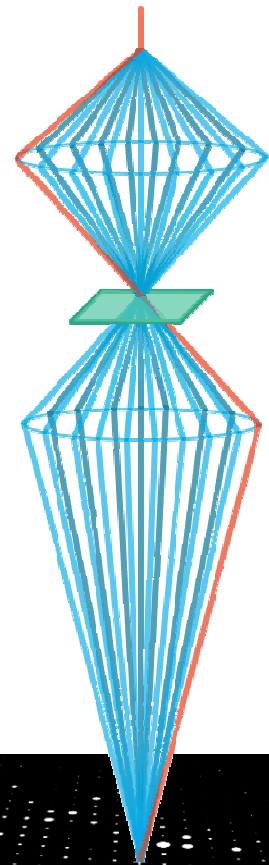
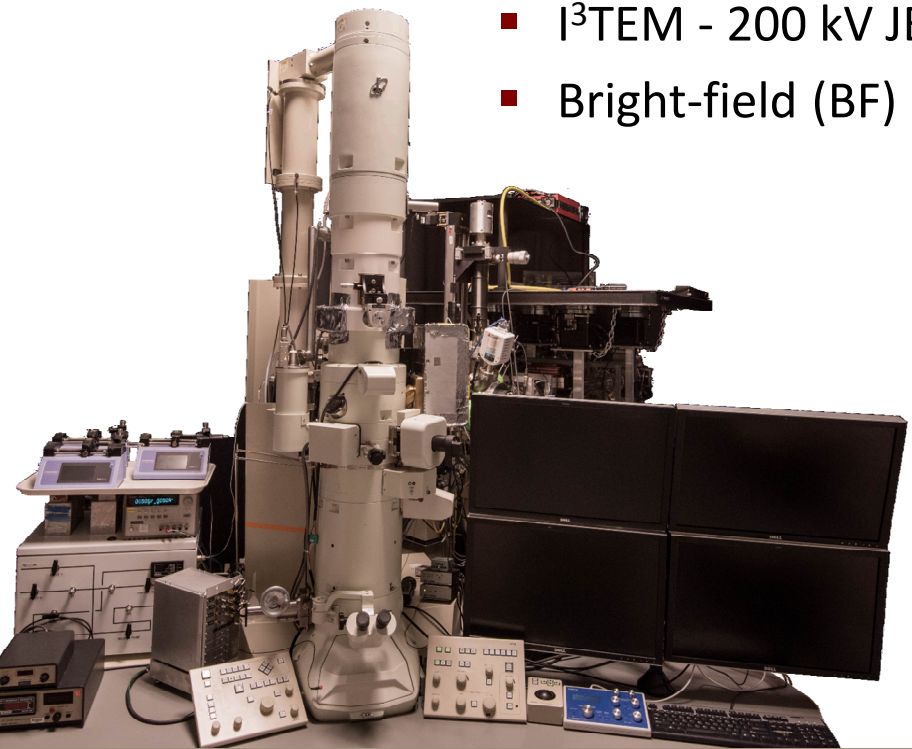
- Sintered at 1000 °C under varied atmospheric conditions

- Atmospheric air (oxidizing)
- Ultra-pure argon (inert)
- Argon-hydrogen (reducing)\*



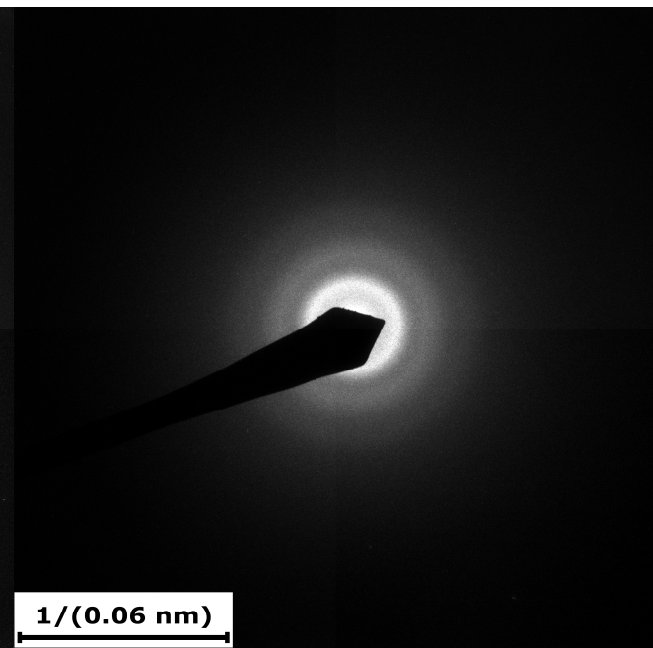
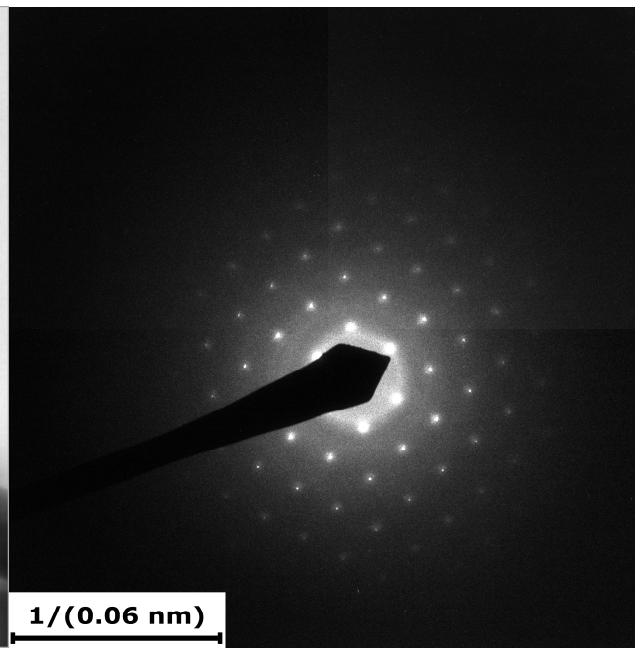
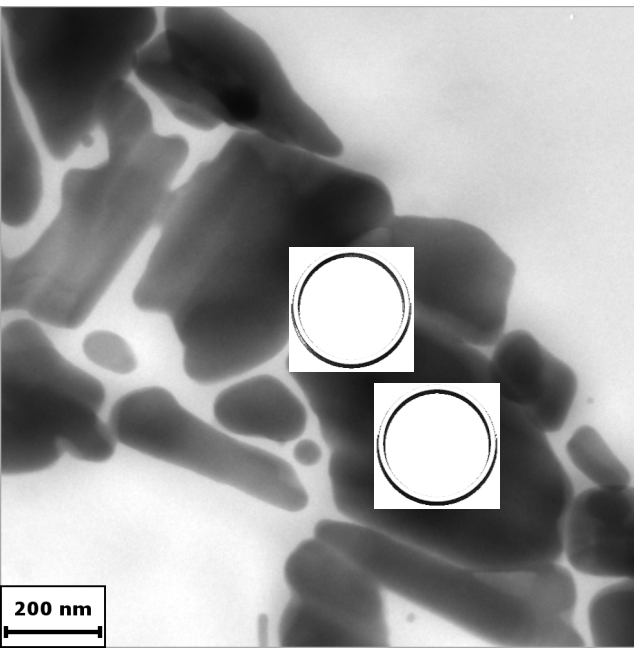
# Experimental Characterization

- Powder X-Ray Diffraction ( $\text{UO}_2$  on Zr-4, Ar sintered)
  - $\theta/2\theta$  scan on PANalytical X'Pert Pro with  $\text{Cu K}_\alpha$  X-rays
  - $0.0167^\circ$  step size,  $0.152^\circ/\text{sec}$  dwell time
- Transmission electron microscopy ( $\text{UO}_2$  on  $\text{Si}_3\text{N}_4$ )
  - Selected area electron diffraction (SAED)
  - Precession electron diffraction (PED)
    - I<sup>3</sup>TEM - 200 kV JEOL 2100
    - Bright-field (BF) imaging



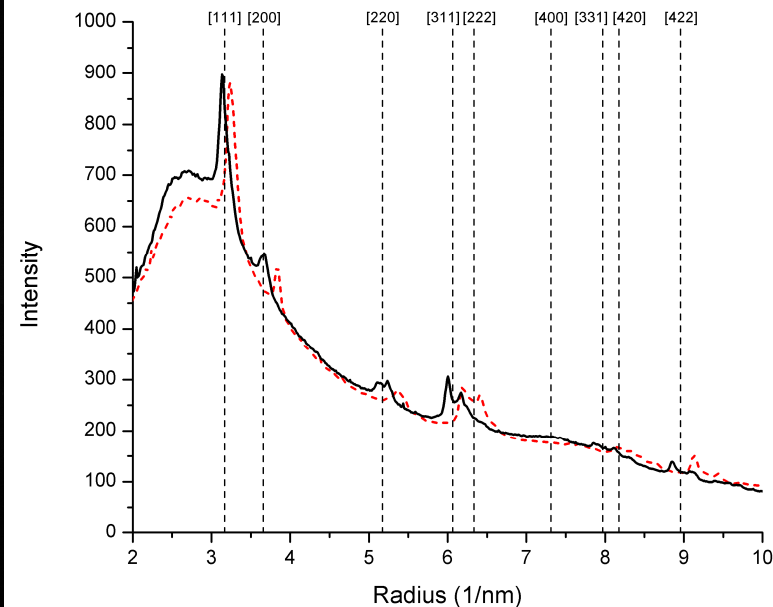
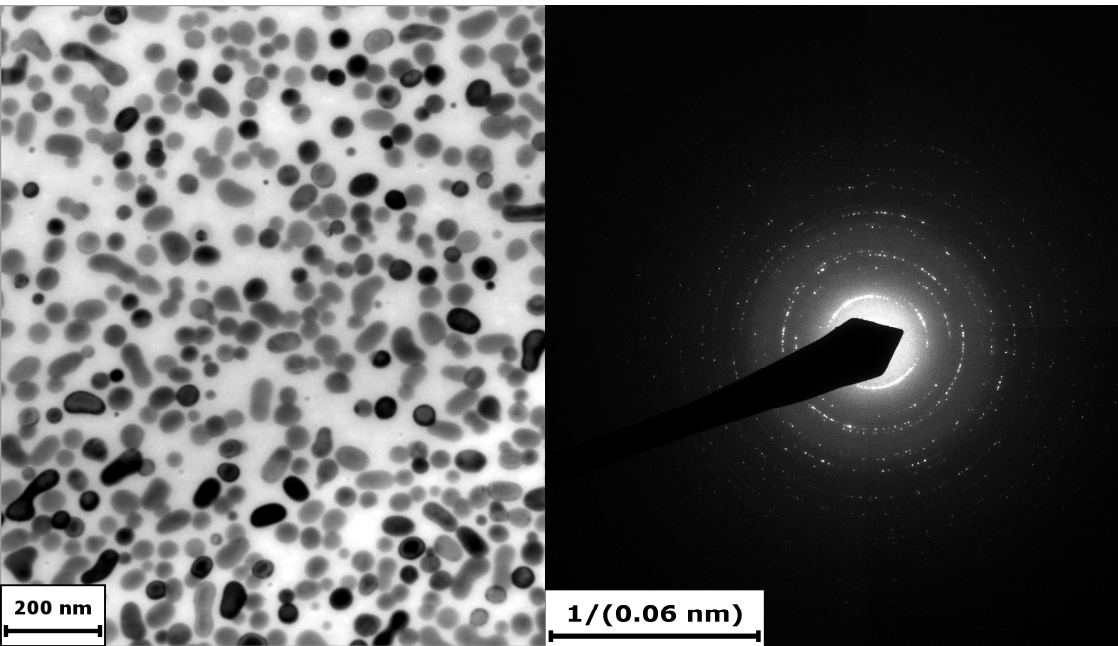
# Atm-sintered $\text{UO}_2$ – TEM Analysis

- “Particles” appeared as large, irregularly-shaped grains
- SAED for smaller, isolated, crystalline grains indicated fcc/fluorite structure consistent with  $\text{UO}_{2\pm x}$  phase
- SAED for majority of particles indicate amorphous rings



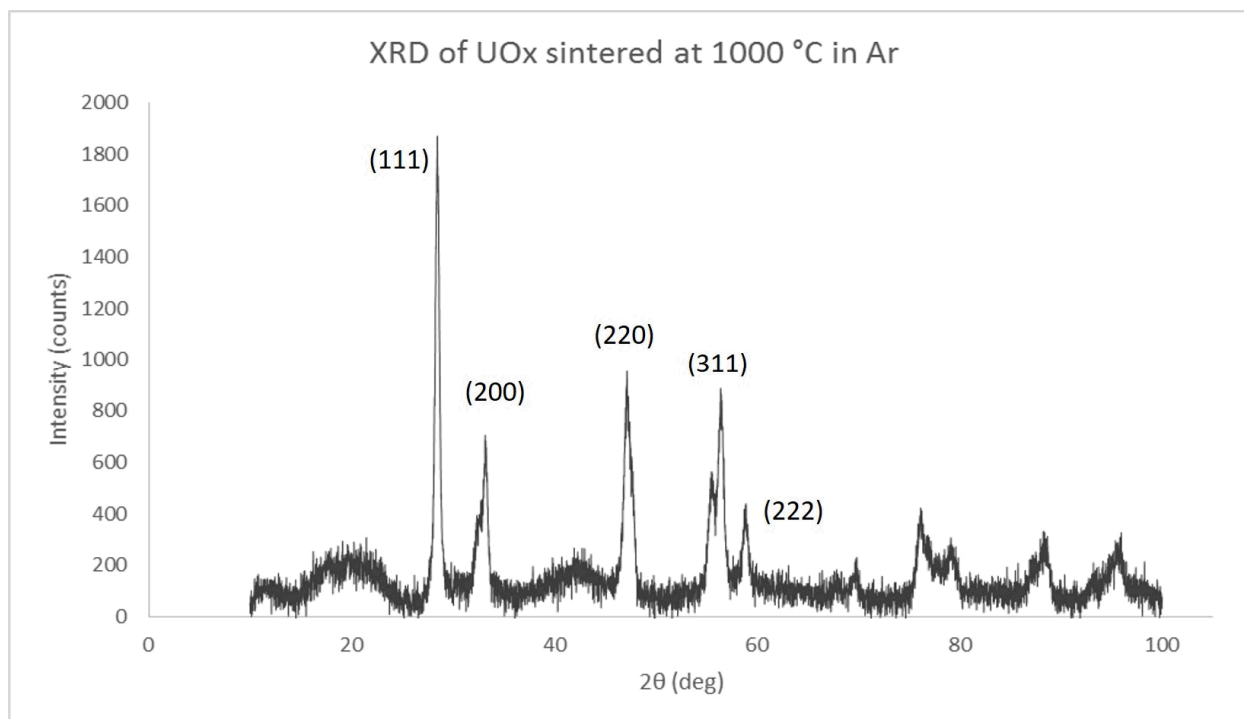
# Ar-sintered $\text{UO}_2$ – TEM Analysis

- Specimens appeared as small, spheroidal particles
- SAED ring pattern spacings appear to be consistent with a  $\text{UO}_{2\pm x}$  phase



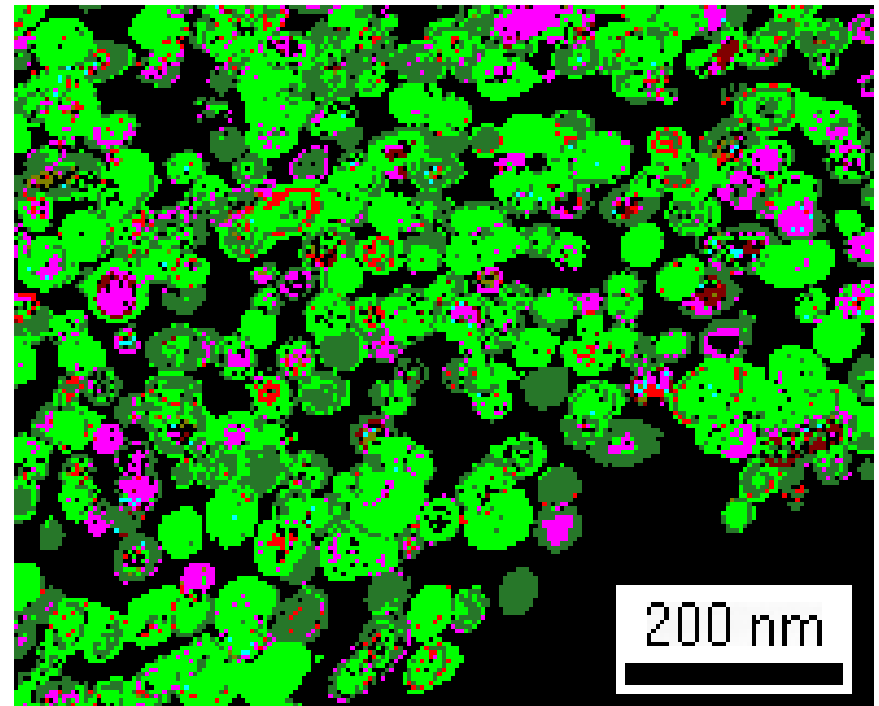
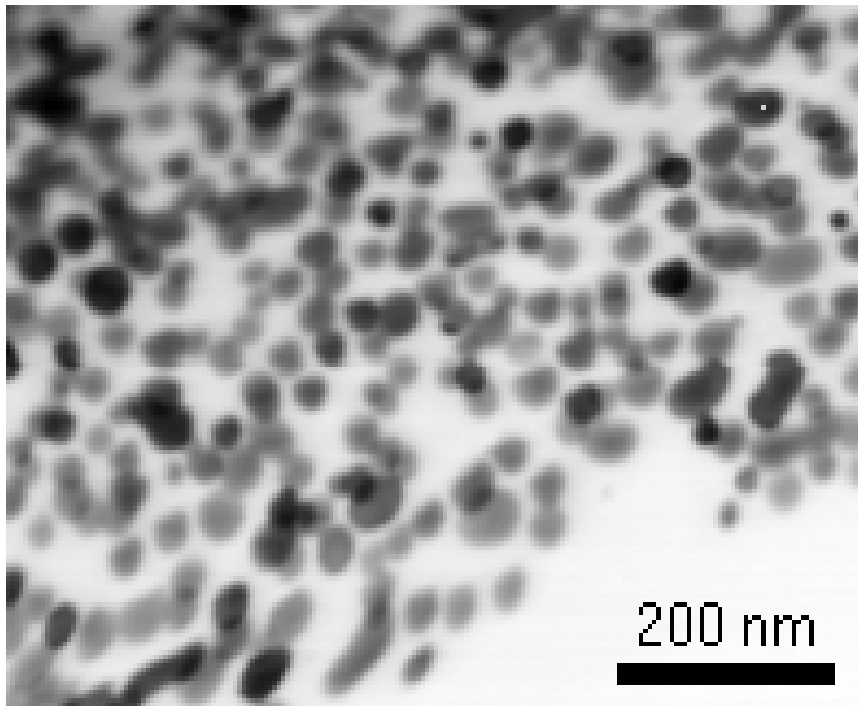
# Ar-sintered $\text{UO}_2$ – PXRD Analysis

- PXRD results show good agreement with SAED analysis
- Peaks consistent with fcc/fluorite structure of  $\text{UO}_{2\pm x}$



# Ar-sintered $\text{UO}_2$ – PED Analysis

- PED not useful for determining exact  $\text{UO}_{2\pm x}$  stoichiometry
- Does appear to confirm that primarily  $\text{UO}_{2\pm x}$  phase is present as opposed to other O-rich phases



# Next Steps

- Synthesize and characterize  $\text{UO}_2$  particles following sintering in reducing (Ar-H) environment
- Attempt in-situ sintering in vacuum
- Grow epitaxial  $\text{UO}_2$  thin films using the PAD technique
- Explore properties and behavior of these particles and thin films in various environments
  - Radiation Tolerance
  - Electrical properties
  - Environmental effects

# Summary & Conclusions

- d- $\text{UO}_{2\pm x}$  nanoparticles have been synthesized using PAD with subsequent 1000 °C sintering in different environments
- Resulting particle phases and structure has been characterized with PXRD and diffraction-based TEM techniques
- Sintering in an oxidizing, aerobic environment results in large (200+ nm), mostly amorphous structures with isolated  $\text{UO}_{2\pm x}$  grains
- Sintering in an inert Ar environment results in a fine dispersion of small (~60 nm) spheroidal particles that all appear to be a  $\text{UO}_{2\pm x}$  phase
- Future efforts seek to investigate the effect of reducing (Ar-H) sintering environments and attempt epitaxial thin-film growth

Thank you for your attention.  
Questions?